

Form 1449 (Modified) Information Disclosure Statement By Applicant (Use Several Sheets if Necessary)	Atty Docket No.	ANDIP037/425584
	Application No.:	10/726,269
	Applicant	Basavaiah, Murali <i>et al.</i>
	Filing Date	December 1, 2003
	Group	2181
		Page 1 of 1
	Submitted:	November 12, 2010

U.S. Patent Documents

Examiner Initial	No.	Patent No.	Date	Patentee	Class	Sub-class	Filing Date
	1.	2005/0192967	9/1/2005	Basavaiah et al.			
	2.	2008/0320134	12/25/2008	Edsall et al.			
	3.	7,433,948	10/7/2008	Edsall et al.			

Foreign Patent or Published Foreign Patent Application

Examiner Initial		Document No.	Publication / Issue Date	Country or Patent Office	Class	Sub-Class	Translation	
							Yes	No
	4.	WO 03/060688 A2	7/24/2003	WIPO				
	5.	WO 03/062979 A2	7/31/2003	WIPO				
	6.	WO 05/055497	6/16/2005	WIPO				

Other Documents

Examiner Initial	No.	Author, Title, Place (e.g. Journal) of Publication, Date
	7.	U.S. Examiner's Answer to Appeal Brief dated July 26, 2010 issued in 10/242,374 (ANDIP005)
	8.	Chinese First Office Action dated October 13, 2006 issued in CN App No. 03806717.X (ANDIP003CN)
	9.	Korean Office Action (Notification of Provisional Rejection) dated December 29, 2009 issued in App. No. 2004-7011405 (ANDIP003KR)
	10.	PCT International Preliminary Examination Report dated February 21, 2005, PCT/US02/41079 (WO/2003/06068 A2) (ANDIP007WO)
	11.	PCT International Written Opinion dated November 29, 2004 issued in PCT/US02/41079 (ANDIP007WO)
	12.	European Examination Report dated July 14, 2010 issued in EP Application 02 797 469.0 (ANDIP007EP)
	13.	PCT International Search Report dated May 23, 2006 issued in PCT/US2004/039904 (ANDIP037WO)
	14.	PCT International Preliminary Report on Patentability and Written Opinion dated May 23, 2006 issued in PCT/US2004/039904 (ANDIP037WO)
	15.	Chinese Third Office Action dated July 19, 2010 issued in CN Application No. 200480033685.4 (ANDIP037CN)

Examiner	Date Considered
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Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.